

Towards solid-state-laser-driven plasma sources of EUV light: An update on ARCNL's Source Research program

Groups:

EUV Plasma Processes (Versolato, Ubachs, Hoekstra)

EUV Generation & Imaging (Witte, Eikema)

Ion interactions – Groningen (Hoekstra)

EUV Plasma Theory & Modelling – NN

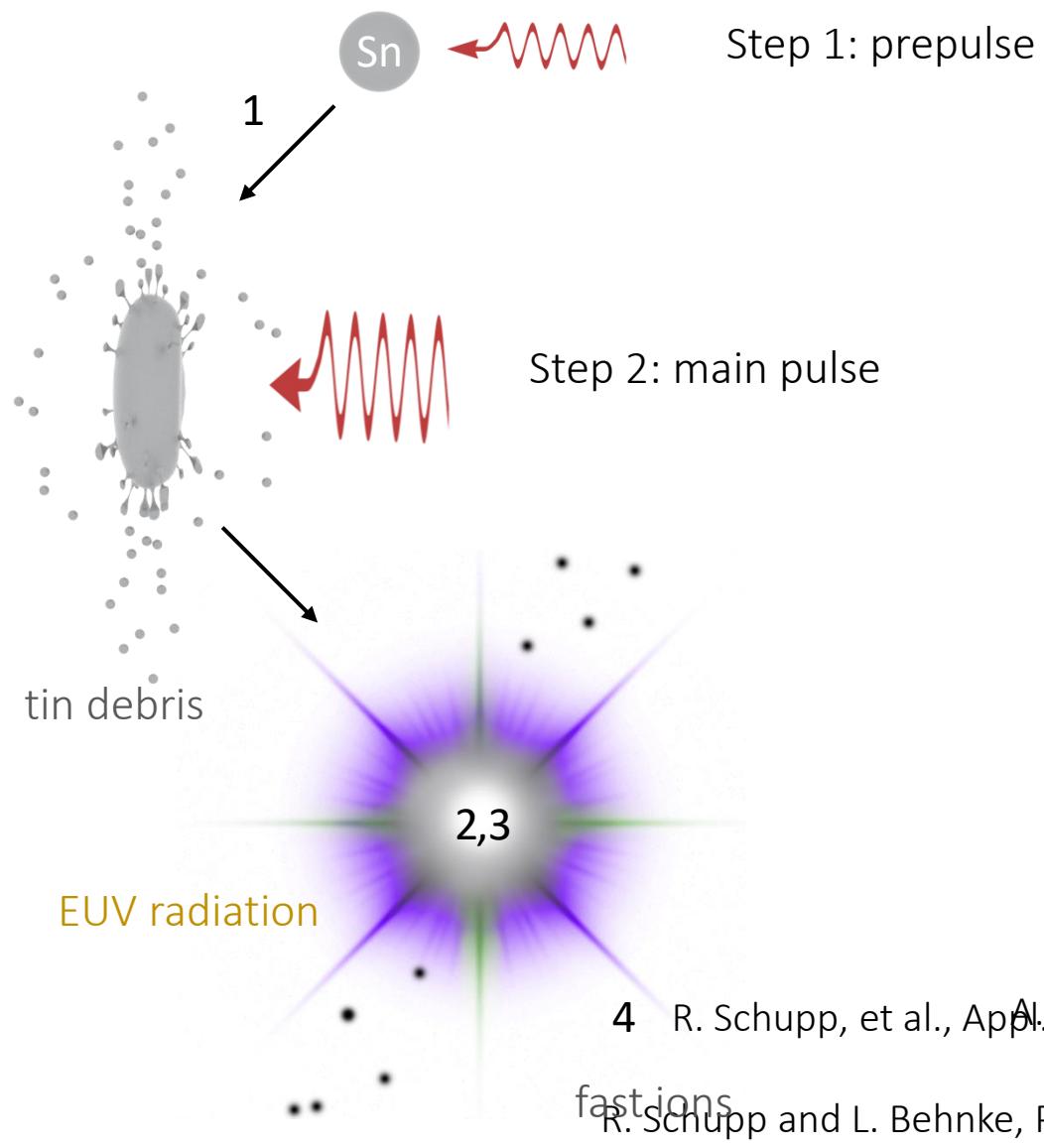
EUVL Workshop - online June 10th, 2020

Oscar Versolato

Head of ARCNL Source Department



ARCNL Source Research: physics challenges



1. Understand exploding tin microdroplets
 - o What determines deformation and fragmentation?
2. Key insights to enable source predictive modeling
 - o What emits that EUV light?
3. Push the fundamental limits of the conversion efficiency
 - o What sets the fundamental limit?
4. Control expansion dynamics of laser-produced plasma
 - o What is the cause of the ion energy distribution?

J. Scheers, et al., PRE **102**, 043014 (2020); J. Scheers, Set. alle, PRA **108**, 082501 (2020);

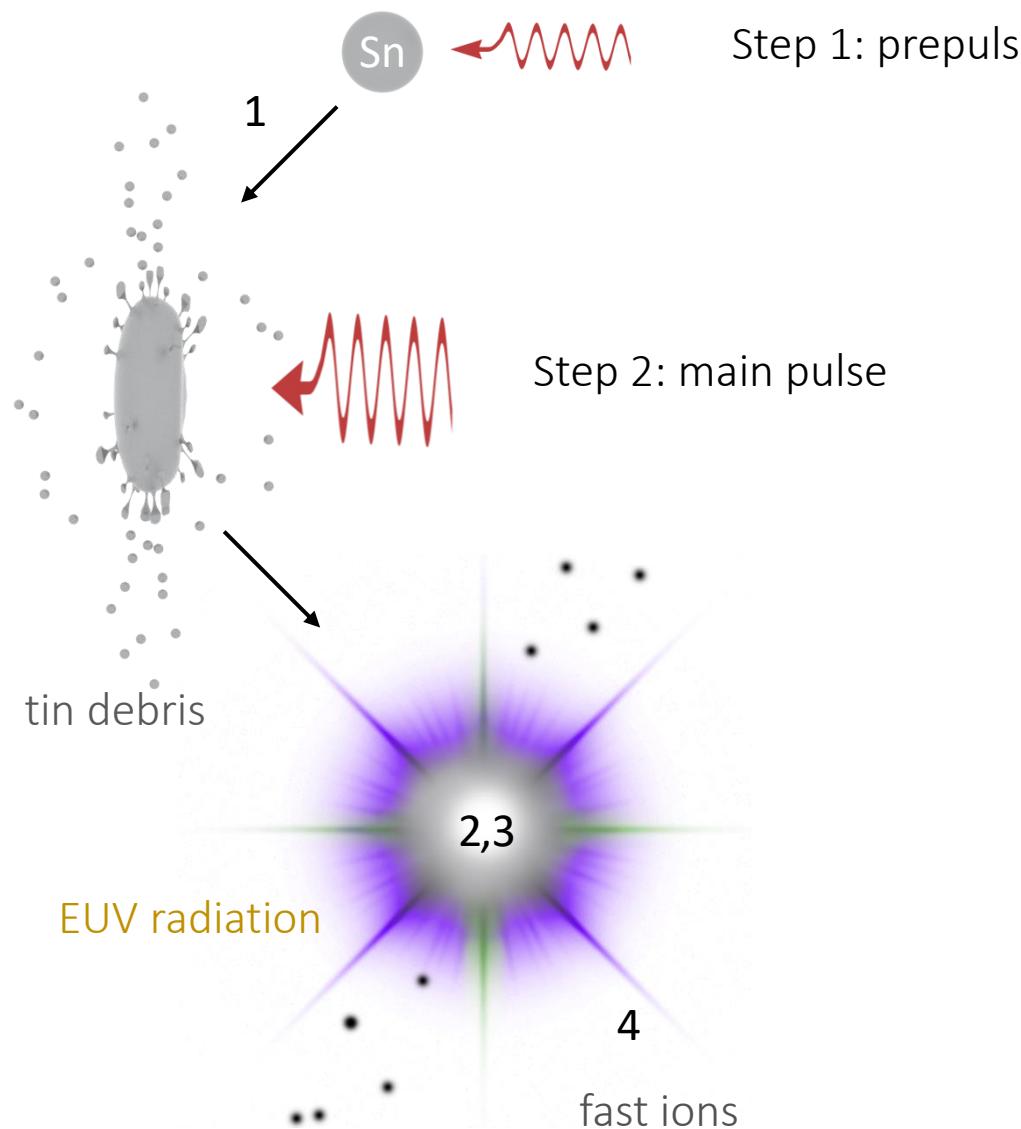
4 R. Schupp, et al., Appl. Phys. Lett. **115**, 124101 (2019); R. Schupp, et al., Phys. Rev. Applied **13**, 014005 (2020);

F. Torretti, J. ShBi, Lefan, N. Umer, et al., Phys. Rev. Applied **13**, 054004 (2020);

R. Schupp and L. Behnke, Phys. Rev. Res. **3**, 013254 (2021); R. Schupp, et al., MBK **43**, 22001 (2020); R. Schupp, et al., MBK **43**, 22002 (2020);

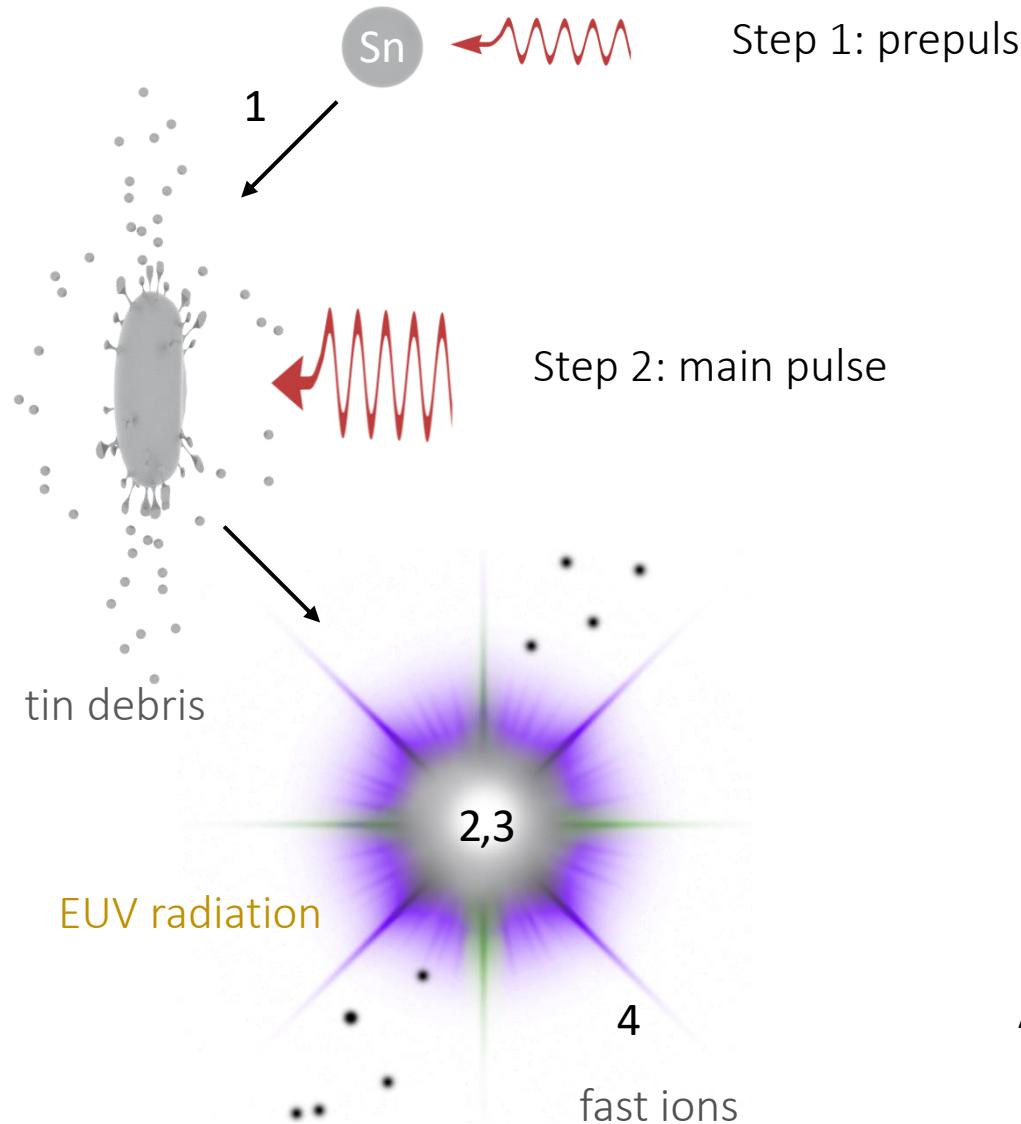
fast ions

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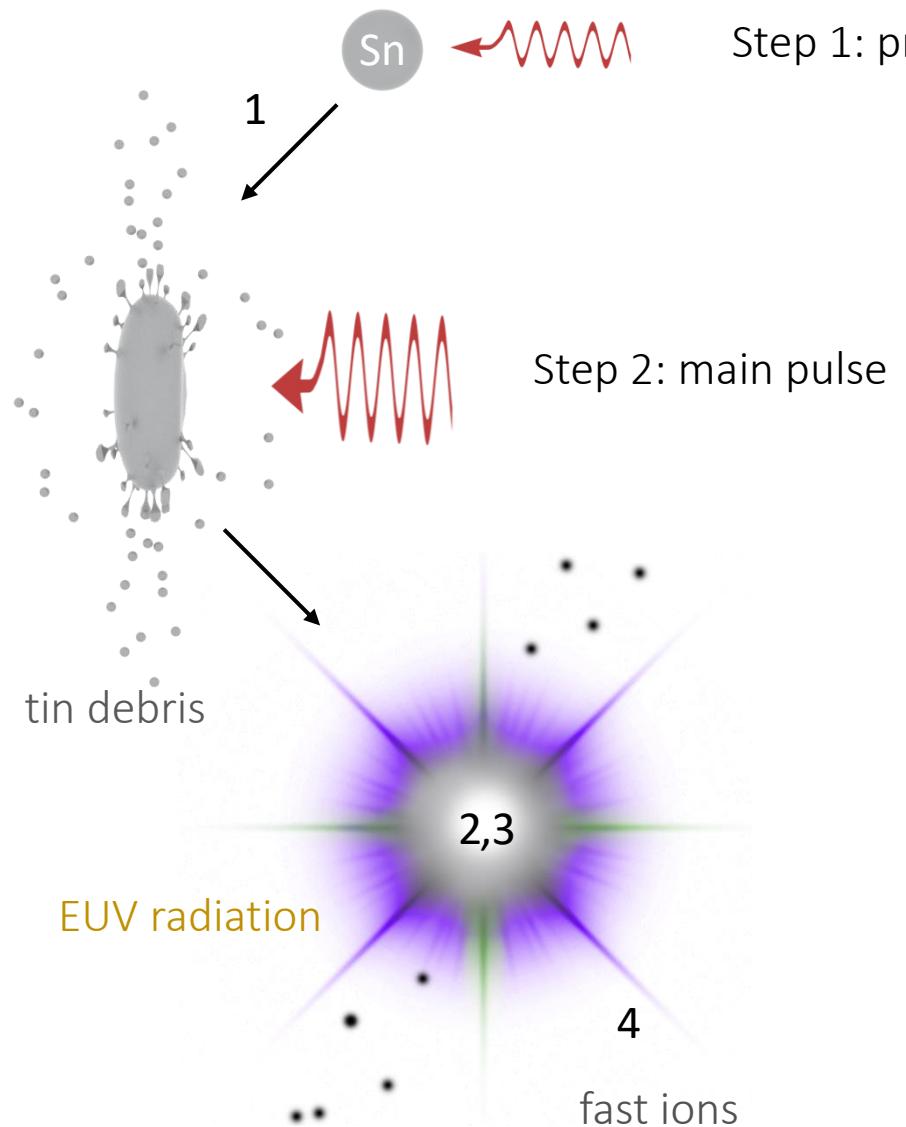
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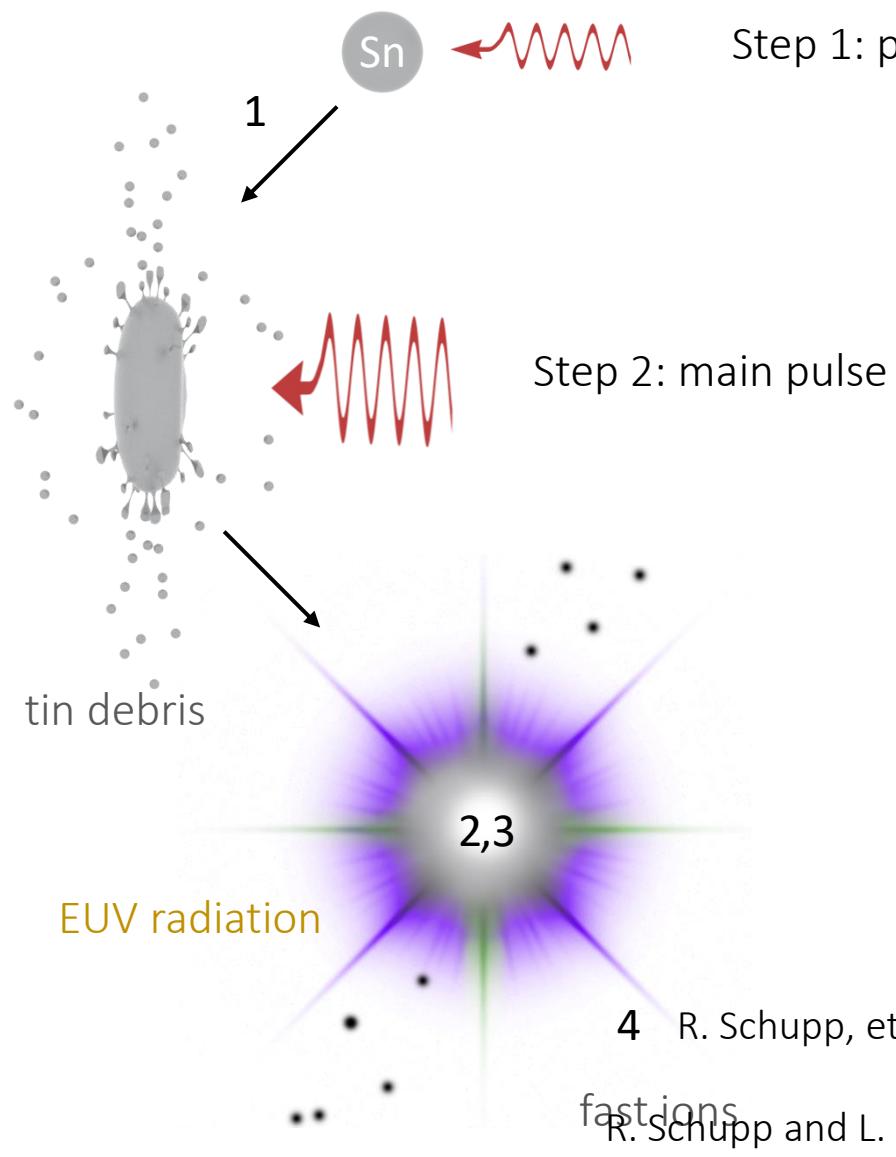
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Z. Bouza and J. Scheers, et al., J. Phys. B **53**, 195001 (2020);
F. Torretti, J. Sheil, et al., Nature Communications **11**, 2334 (2020);
J. Sheil, et al., J. Phys. B. **54**, 035002 (2021)

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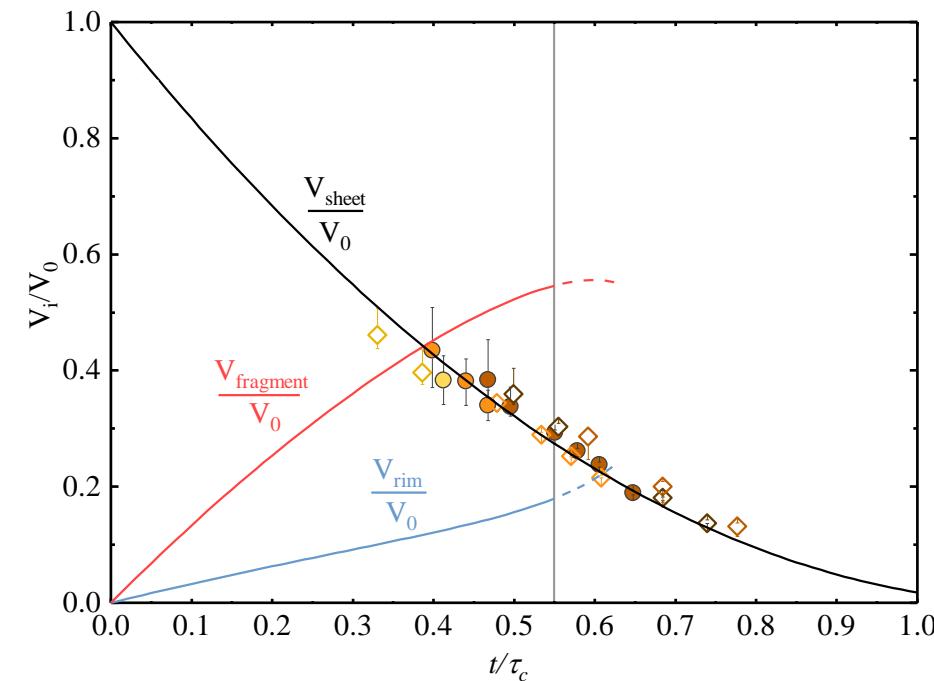
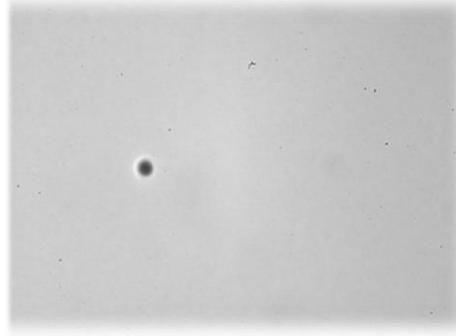
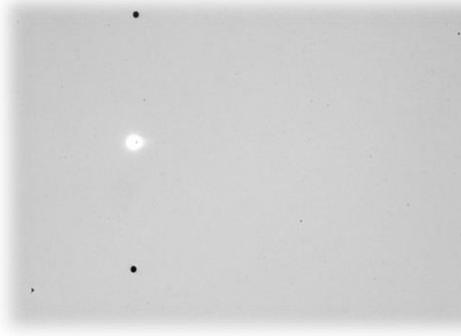
O.O. Versolato, Plasma Sources Sci. Technol. **28**, 083001 (2019);

4 R. Schupp, et al., Appl. Phys. Lett. **115**, 124101 (2019); R. Schupp, et al., Phys. Rev. Applied **12**, 014010 (2019);

F. Torretti, et al., J. Phys. D. **53**, 055204 (2019);

R. Schupp and L. Behnke, Phys. Rev. Res. **3**, 013294 (2021), L. Behnke and R. Schupp, Opt. Express **29**, 4475 (2021)

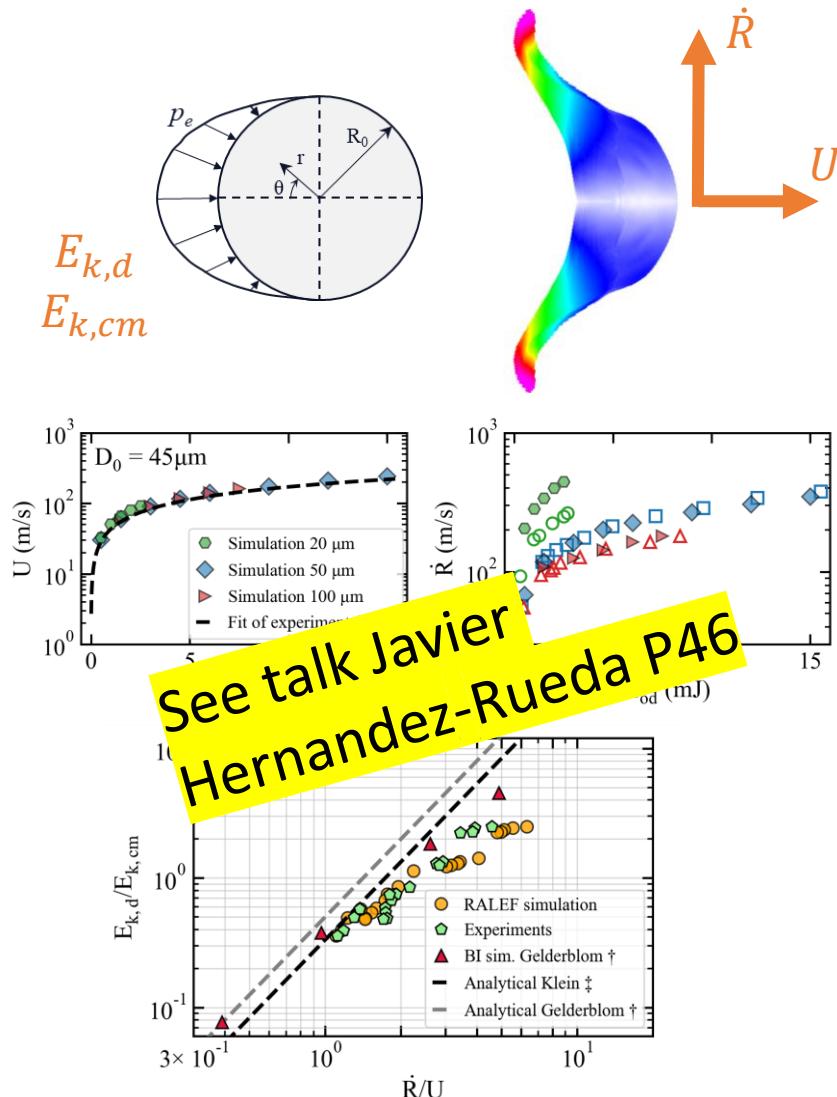
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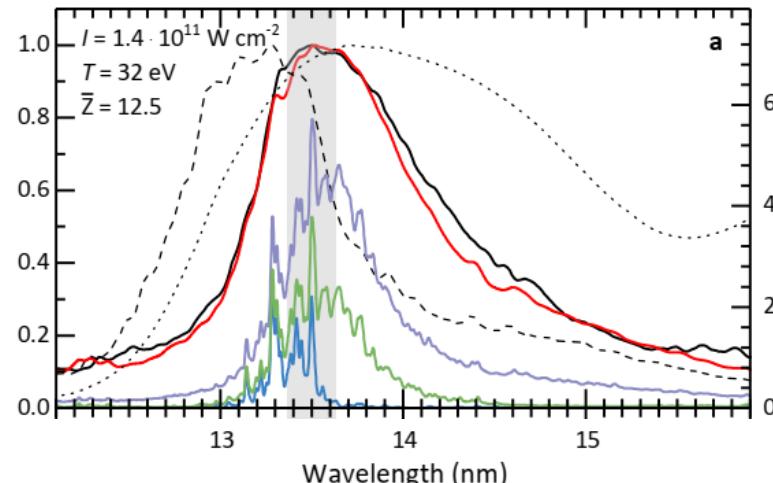
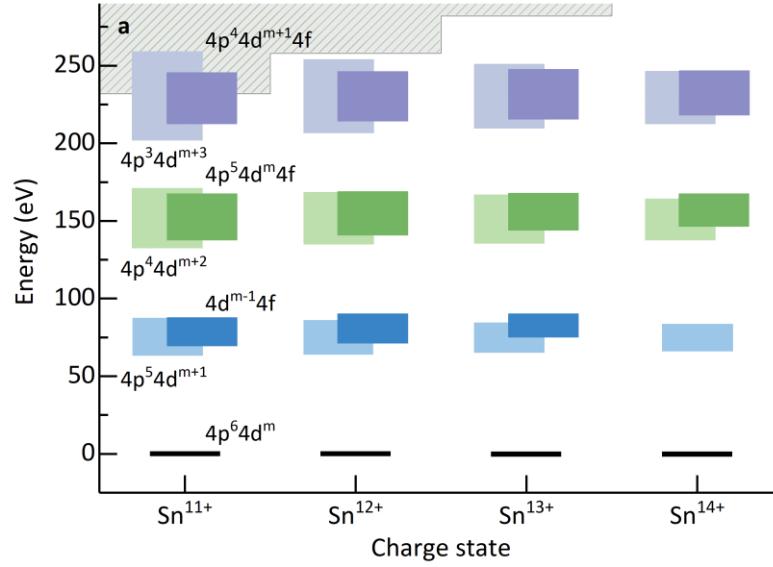
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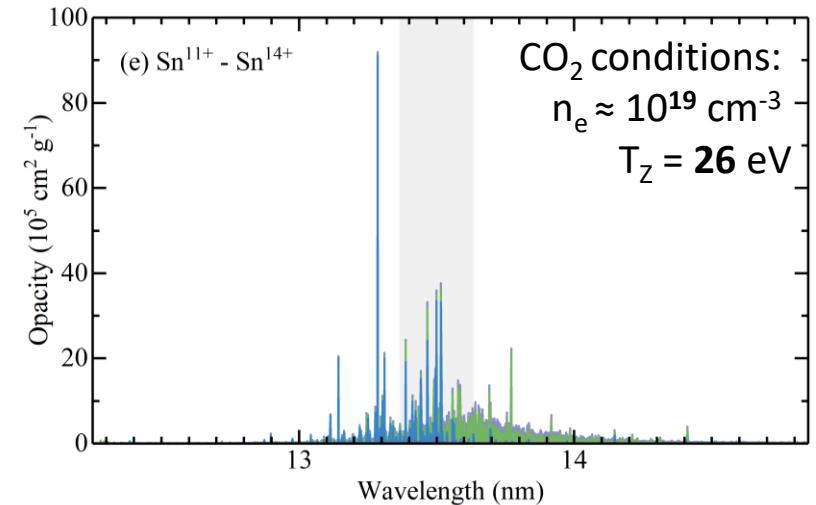
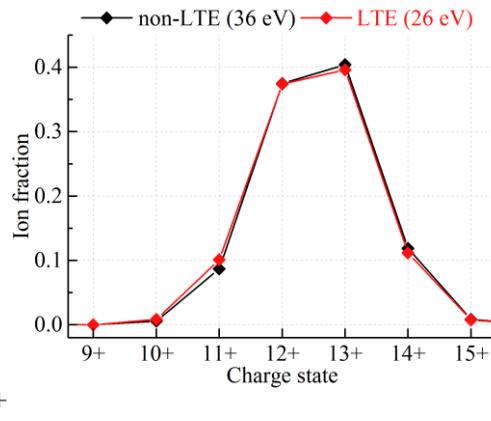
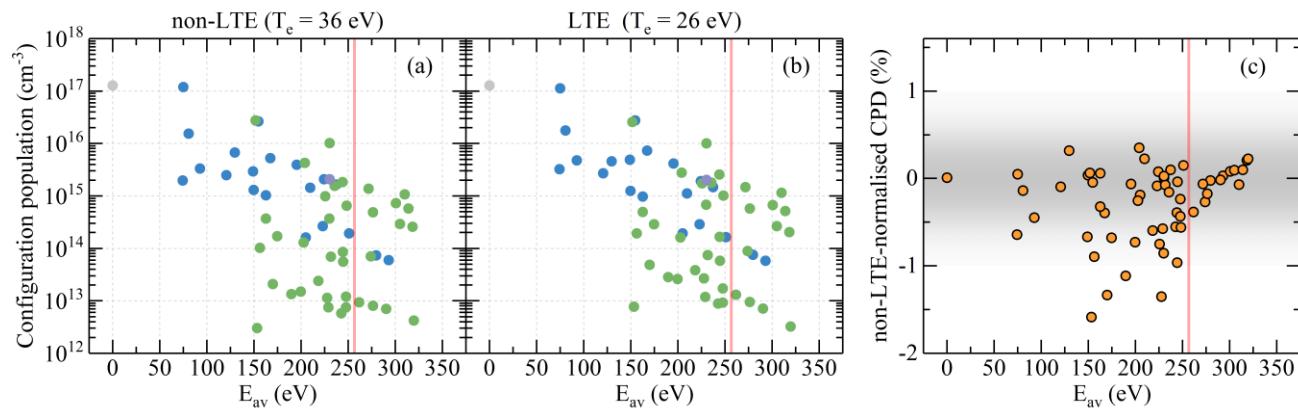
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What emits that EUV light?

Busquet's method:
approximate non-LTE level
populations using LTE
-- for CO₂-laser-driven plasma



Majority (CO₂ case: 66%) of 2%BW opacity from transitions between multiply-excited states

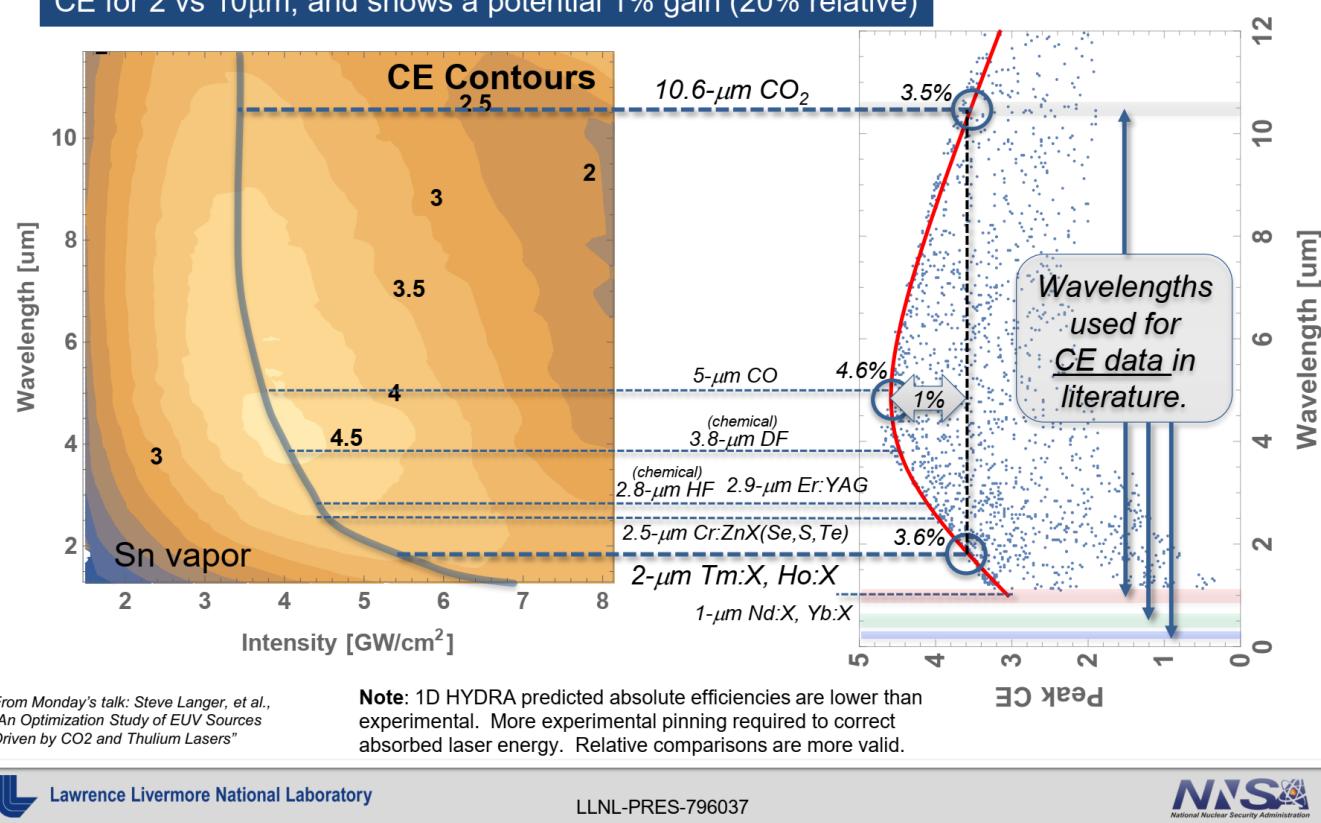
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Push the fundamental limits of CE

For this 2019 EUV Source Workshop, we haven taken the first steps in this system-level EUV source trade study

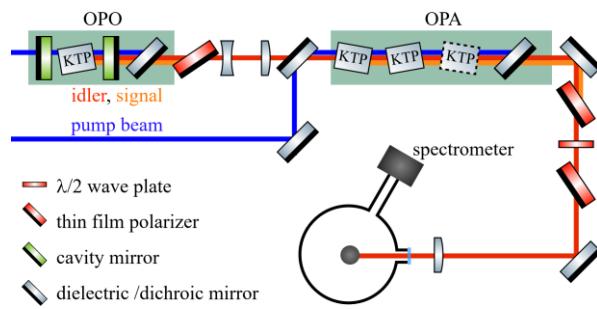
1D HYDRA ensemble modeling agrees with our earlier on-par CE for 2 vs 10 μm , and shows a potential 1% gain (20% relative)



Research at ARCNL: “Contribute to >500 Watt EUV LPP source beyond 2020; pushing the fundamental limits of the conversion of **solid-state drive laser** light into EUV light”

Up to now: max CE for YAG (1 micron, MP only) at ~3% at ARCNL* – limited by its large optical depth

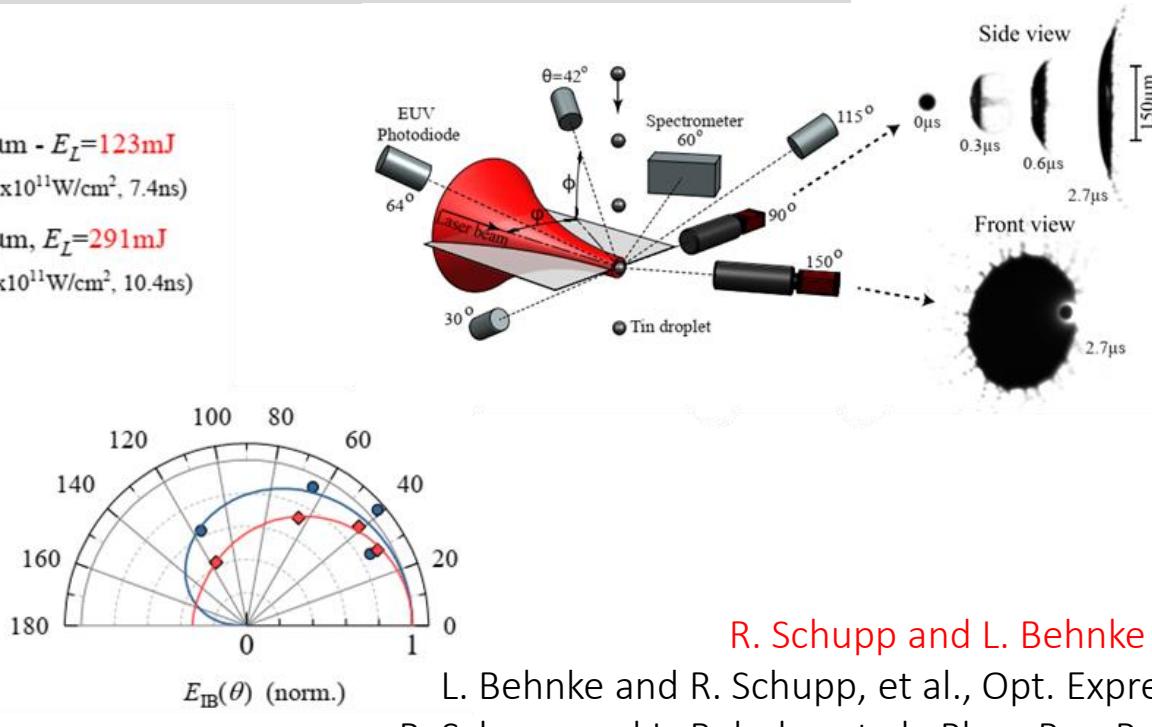
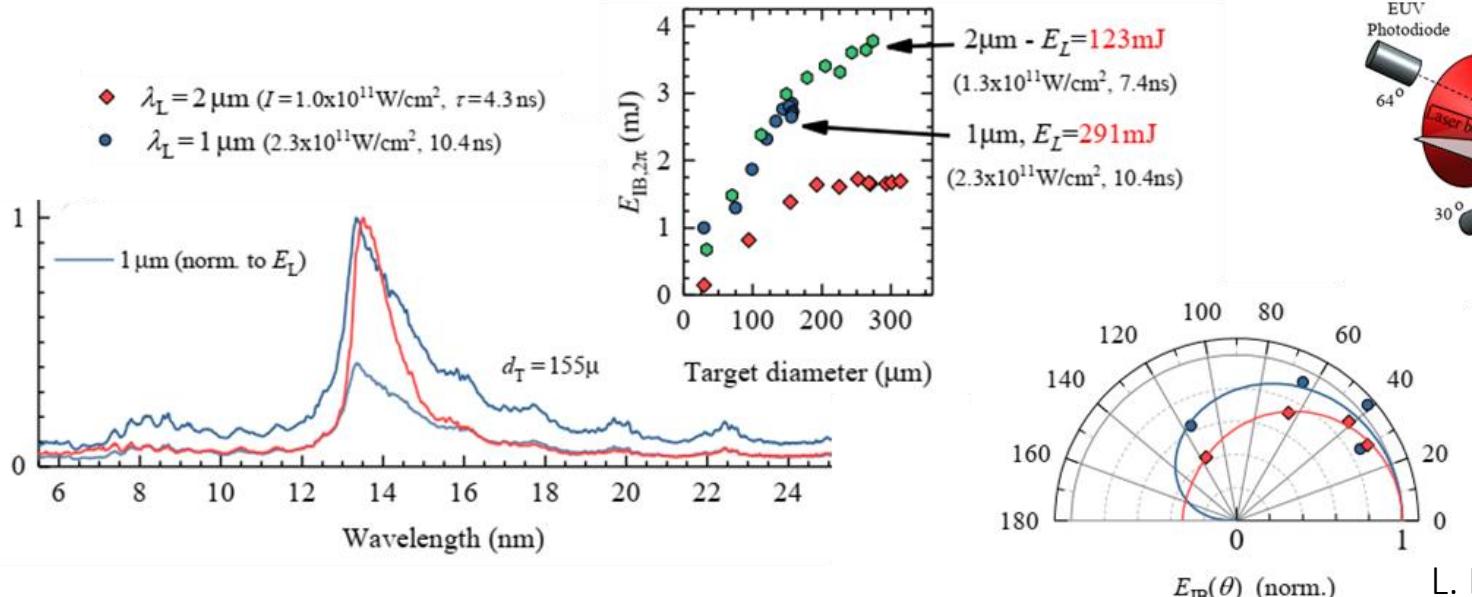
Key question: what laser operating at what wavelength should best be used to drive plasma for next-generation’s EUV light sources?



Push the limits of CE

Characterization of angularly resolved EUV emission from 2- μm -wavelength laser-driven Sn plasmas using preformed liquid disk targets

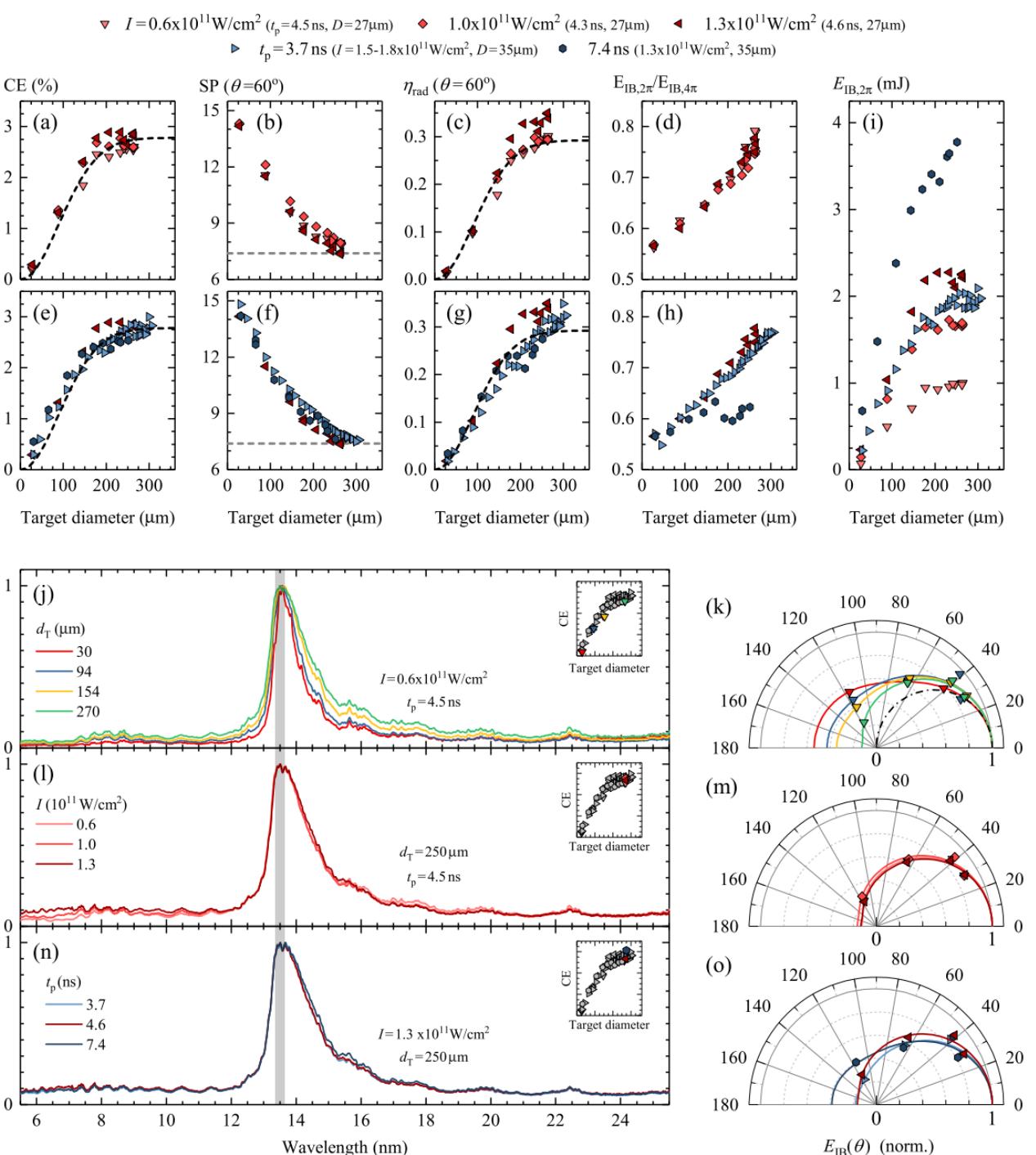
Enhanced capabilities and performance of 2- μm -driven plasmas produced from disk targets when compared to 1- μm driven plasmas



R. Schupp and L. Behnke et al, under review;
L. Behnke and R. Schupp, et al., Opt. Express 29, 4475 (2021);
R. Schupp and L. Behnke, et al., Phys. Rev. Res. 3, 013294 (2021)

Push the limits of CE

- CE and EUV emission geometrically increase with target diameter, while SP decreases
- CE, SP independent on 2 micron laser pulse intensity – EUV emission increases with input power
- CE, SP independent on 2 micron laser pulse length – EUV emission increases with input power
- CE, SP strongly increase with drive laser wavelength 1->2 micron



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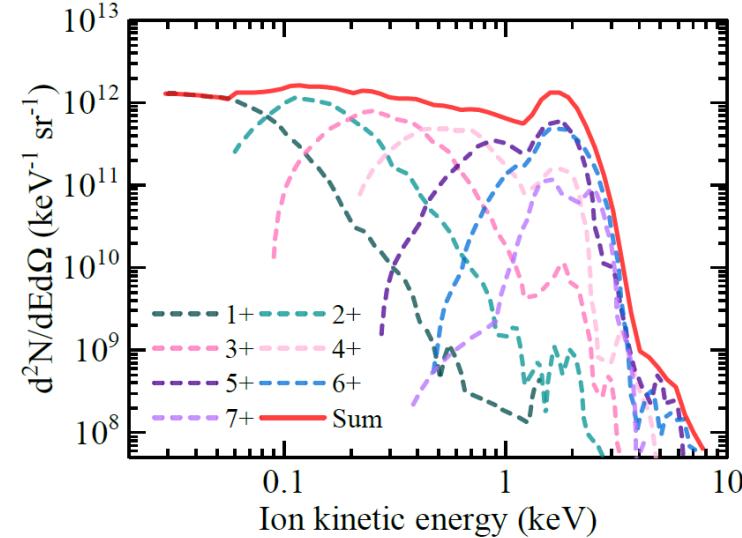
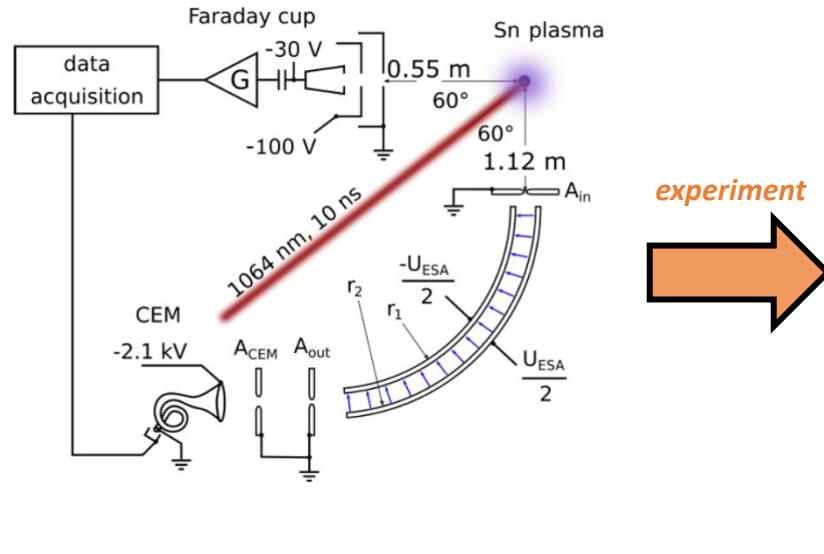
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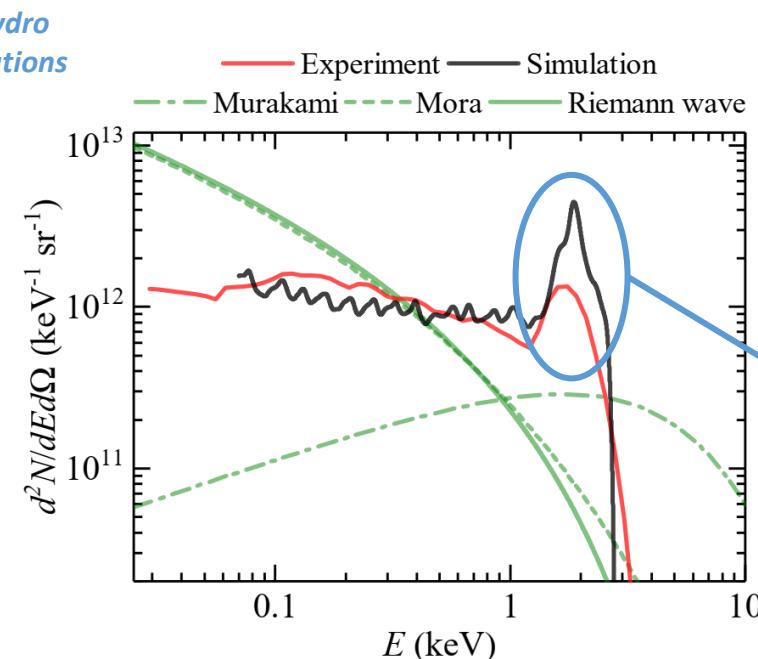
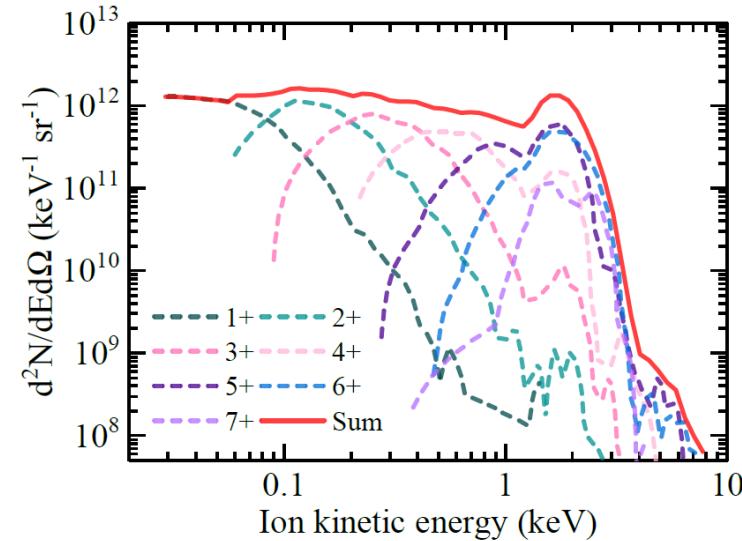
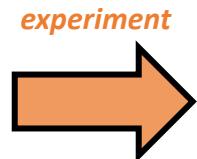


What is the cause of the ion energy distribution?

Hydro approach valid when the local Debye length $\lambda_D \ll L$ (flow scale variation).

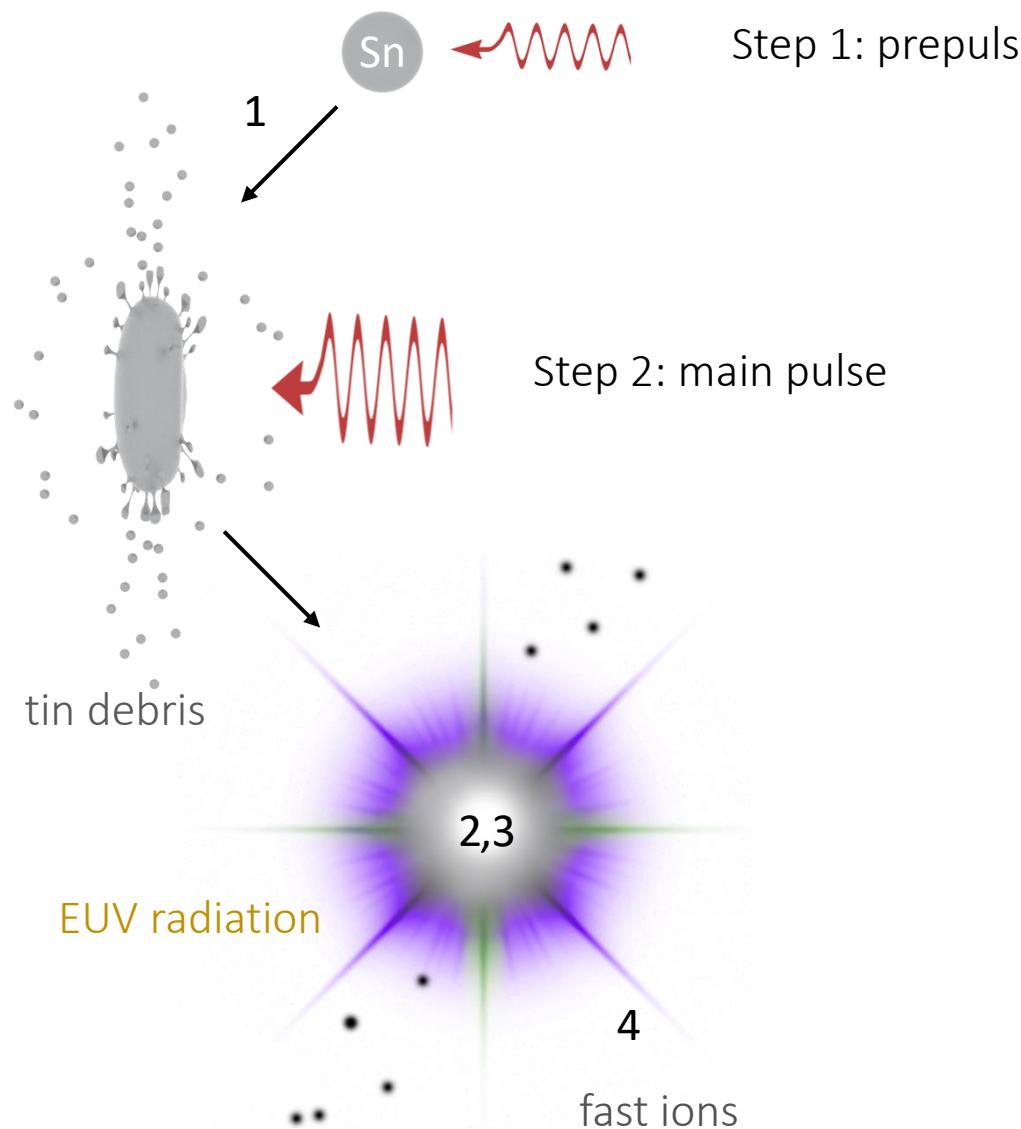
High pressure in hot, dense plasma drives expansion. For an ideal gas with moderate ionization degrees:

$$P \approx n_e k T_e = Z n_{ion} k T_e$$



Ion energy peak attributed to high-velocity, dense shell formed early; subsequent higher velocity plasma (from intense part of pulse) shocks into this shell.

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ARCNL Source Research: team

ARCNL EUV PP team:

Ruben Schupp (PhD defense March 2021)
Zoi Bouza (TKI PhD)
James Byers (TKI PD @ UT)
Bo Liu (VIDI PhD)
Lars Behnke (VIDI PhD)
Lucas Poirier (ERC PhD)
Yahia Mostafa (ERC PhD)
N.N. (PhD)
Adam Lassise (PD)
Javier Hernandez-Rueda (ERC PD)
Randy Meijer (PhD -> PD)
Laurens van Buuren (technician)
Ronnie Hoekstra (group leader)
Wim Ubachs (group leader)
Oscar Versolato (group leader)



UNIVERSITEIT VAN AMSTERDAM



ARCNL EUV G&I team:

Jan Mathijssen (PhD)
Zeudi Mazzotta (PD)
Stefan Witte (group leader)
Kjeld Eikema (group leader)

RUG-ARCNL team:

Subam Rai (PhD, RUG)
Klaas Bijlsma (PhD, RUG)
N.N. (PhD)
Mart Salverda (technician)
Ronnie Hoekstra (group leader)



SOURCE Plasma modeling team

+ N.N (Tenure-track group lead)
John Sheil (PD)
Diko Hemminga (ERC PhD)

Academic collaborators:

James Colgan (LANL): plasma theory (opacity)
A. Ryabtsev (ISAN): spectroscopy
M. Basko (KIAM, ISAN): plasma
J.R. Crespo López-Urrutia (MPIK): spectroscopy
H. Gelderblom (TU/e): fluids
A. Borschevsky (U. of Groningen): atomic theory
J. Berengut (UNSW Australia): atomic theory
Ahmed Diallo et al. (PPPL Princeton): thomson & PIC modeling
Mendez, Rabalan (UAM-Madrid): charge exchange
Muhamrem Bayraktar, Fred Bijkerk, *Marcelo Ackermann* (U. Twente): spectroscopy

Total staff currently involved in Source:

4 PI's (~ 2 fte), 5- postdocs, 9 PhD students,
2 technicians; (3 vacancies)





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